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APPLICATION NO.	į i	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/802,924	09/802,924 03/12/2001		Fu-Sheng Chen	06484.0070	1250	
22852	7590	08/09/2004		EXAMINER		
	N, HENI	DERSON, FARAB	NGUYEN, DANNY			
LLP 1300 I STRE	EET, NW		ART UNIT	PAPER NUMBER		
WASHINGT			2836			
				DATE MAILED: 08/09/2004	1	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicati	on No.	Applicant(s)					
Office Action Summary			24	CHEN, FU-SHEN	CHEN, FU-SHENG				
			r	Art Unit					
		Danny N	· ·	2836					
Period fo	The MAILING DATE of this communica or Reply	tion appears on the	e cover sheet wit	h the correspondence ad	ldress				
THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA nsions of time may be available under the provisions of 3 SIX (6) MONTHS from the mailing date of this communication of the period for reply specified above is less than thirty (30) do period for reply is specified above, the maximum statutore to reply within the set or extended period for reply will, reply received by the Office later than three months after end patent term adjustment. See 37 CFR 1.704(b).	ATION. 7 CFR 1.136(a). In no everation. ays, a reply within the state only period will apply and well by statute, cause the app	ent, however, may a re tutory minimum of thirty ill expire SIX (6) MONT Dication to become ABA	ply be timely filed (30) days will be considered timel (HS from the mailing date of this of ANDONED (35 U.S.C. § 133).	ly. ommunication.				
Status									
1)	Responsive to communication(s) filed of	on							
2a) <u></u> ☐	This action is FINAL . 2b)		on-final.						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Dispositi	on of Claims								
4)⊠ 5)□ 6)⊠ 7)□	4) ☐ Claim(s) 1,3-9 and 17-19 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1,3-9 and 17-19 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or election requirement.								
Applicati	on Papers								
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.									
Priority u	ınder 35 U.S.C. § 119								
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 									
Attachmen	t(s)								
	e of References Cited (PTO-892)	0.40\	4) Interview Su						
3) 🔲 Inforr	e of Draftsperson's Patent Drawing Review (PTO- nation Disclosure Statement(s) (PTO-1449 or PTC r No(s)/Mail Date	948) D/SB/08)		/Mail Date formal Patent Application (PTC _·	D-152)				

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Response to Arguments

1. Applicant's arguments, see Remark filed 07/06/2004, with respect to claims 1 and 17 have been fully considered and are persuasive. The final rejections of 1, 3-9 and 17-19 have been withdrawn.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, 3-6, 9, 17-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tepman (USPN 5,951,775) in view of Sumnitsch (USPN 6,056,825).

Regarding to claims 1, 5, 17, 18, Tepman discloses a chuck system for supporting a semiconductor wafer (see fig. 1 and 2) comprises a chuck platform (16) for supporting the semiconductor wafer, lift structure (see fig. 2) movably coupled to the platform to receive the wafer (14), including a lift base (shown in fig. 2) and at least one lift pin (30) removably coupled to the base, the lift pin having two ends with a first end removably coupled to the base and the second end coupled for supporting the wafer during operation of the lift structure, wherein the first lift pin is threaded. Tepman does not disclose the lift base has a thread hole. Sumnitsch discloses a semiconductor processing apparatus having a lift base (14) with a thread hole (32) for lift pins (fig. 2, col. 3, lines 19-27). It would have been obvious to one of ordinary skill in the art at the

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time the invention was made to incorporate the threaded hole as disclosed by Sumnitsch into the lift base of Tepman in order to engage the lift pins without screws.

Regarding claim 3,Tepman discloses the system comprises a bolt (shown in fig. 2), wherein the first end of the lift pin (first pin 30) is threaded and the bolt removably couples the lift pin with the base through an opening provided by the lift base.

Regarding claims 4, 9,Tepman discloses the lift structure comprises a plurality of pins (30) coupled to the lift base and the lift base is flat and provides one opening for receiving the pins (30) (see fig. 2).

Regarding to claim 6, Tepman discloses the chuck system is an electrostatic chuck system (fig. 2).

Regarding to claim 19,Tepman discloses that the chuck system comprises a driving mechanism (driving mechanism 18) for driving the lift structure, the lift base having at least one mounting hole to mount the lift structure to the driving mechanism, wherein the mounting hole is positioned closer to the center of the lift base than the lift pin (shown in fig. 2).

3. Claims 7, 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tepman in view of Sumnitsch, and Morita et al. (USPN 5,815,366). Tepman and Sumnitsch disclose all limitations of claim 1 as discussed above, but do not disclose the lift pin connected to ground when the lift receives the wafer. Morita discloses a lift pin connected to ground (ground circuit 30 shown in fig. 2). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have modified the circuit of Tepman and Sumnitsch to use a ground circuit connected to the lift pin as

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taught by Morita in order to discharge electrostatic charges on the wafer during lifting operation, which would allow the wafer to be lifted easier since it will no longer be attracted to the chuck.

Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Danny Nguyen whose telephone number is (571)-272-2054. The examiner can normally be reached on Mon to Fri 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Brian Sircus can be reached on (571)-272-2058. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DN 7/28/2004

BRIAN SIRCUS
SUPERVISORY PATENT EXAMINER
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